



ETH
7-28-00

In re application of: Trung T. Doan

Serial No.: 09/133,989

Filed: August 14, 1998

For: CHEMICAL DISPENSING SYSTEM
FOR SEMICONDUCTOR WAFER
PROCESSING

§ Group Art Unit: 1734

§ Examiner: L. Edwards

§ Atty. Docket: 93-0421.03

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Certificate of Mailing (37 C.F.R. § 1.8)

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231, on the date below:

7-19-00
Date

Signature

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136(a)

Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

Applicant hereby petitions to extend the period for response to the Office Action mailed March 21, 2000 for one (1) month, from 6/21/00 to 7/21/00.

Accordingly, the requisite fee is \$ 110. The Commissioner is requested to charge this fee, and any additional fee which may be required to Micron Technology, Inc. Deposit Account 13-3092, Order No. 93-0421.03. A duplicate copy of this petition is enclosed.

Respectfully submitted,

Date: ^{CB} ~~7/21~~ 7/17/00

Charles Brantley
Charles Brantley
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Micron Technology, Inc.
8000 S. Federal Way
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